CLAIMS

- 1. A process for cleaning an integrated circuit package surface, comprising: introducing said integrated circuit inside a plasma chamber; and exposing said integrated circuit to a plasma said plasma being a physical plasma.
- 2. The cleaning process according to Claim 1, wherein said physical plasma has a halogen-type behavior.
- 3. The cleaning process according to Claim 1 wherein said physical plasma is obtained in the presence of a pure noble gas.
- 4. The cleaning process according to Claim 3, wherein said noble gas is argon.
- 5. The cleaning process according to Claim 1 wherein said step of exposing said integrated circuit to a physical plasma comprises the step of energizing said physical plasma by applying the following energization parameters: energization time, between 12 and 15 seconds; energization power, between 140 and 160 W; and plasma chamber pressure, between 190 and 210 millitorr.
 - 6. The cleaning process according to Claim 1, further including: applying a continuous voltage to obtain ionization of said plasma.
- 7. The cleaning process according to Claim 1, further including: applying a radio-frequency voltage at a frequency of between 1 kHz and 100 GHz, to obtain ionization of said plasma.

- 8. The cleaning process according to Claim 1 wherein the exposing of said integrated circuit to a physical plasma occurs in a single exposure.
- 9. The process according to Claim 1 wherein the package is composed of a ceramic material.
- 10. The manufacturing process according to Claim 1, wherein said ink marking process is carried out using a laser ink marking technique.
- 11. The process according to Claim 1 wherein the package is composed of a plastic material.
- 12. The process according to Claim 1 wherein the package is composed of an epoxy resin material.
- 13. The process according to Claim 1 wherein the package includes exposed metal components.
- 14. A process for manufacturing an integrated circuit, comprising:
 cleaning of an integrated circuit package surface by introducing the packaged integrated circuit into a plasma chamber;

exposing the package surface to a physical plasma;

removing a layer of material from the package surface to clean the upper surface of the package; and

ink marking said package surface.

15. The manufacturing process according to Claim 14, wherein said ink marking process is carried out using a laser ink marking technique.

- 16. The process according to Claim 14 wherein the package is composed of a ceramic material.
- 17. The process according to Claims 14 wherein the package is composed of a plastic material.
- 18. The process according to Claim 14 wherein the package is composed of an epoxy resin material.
- 19. The process according to Claim 14 wherein the package includes exposed metal components.